

DO NOT
ENTER
7/19/2006
PATENT

IBM/319

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Toshiharu Furukawa, et al. Confirmation No. 5763
Serial No.: 10/711,764
Filing Date: October 4, 2004
Examiner: Jarrett J. Stark
Art Unit: 2823
Title: **LOW-K DIELECTRIC LAYER BASED UPON CARBON
NANOTUBES** (formerly entitled LOW-K DIELECTRIC MATERIAL
BASED UPON CARBON NANOTUBES)
Atty. Docket No.: BUR920040152US1

AMENDMENT UNDER 37 C.F.R. § 1.116

Mail Stop AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the final Office Action dated April 13, 2006, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims that begins on page 3 of this paper.

Remarks begin on page 7 of this paper.